

	L #	Hits	Search Text	DBs	Time Stamp
1	L1	3643	(porous pore porosity porogen micropor\$6 nanopor\$6 void) same (dry drying dried evaporat\$4 vaporiz\$6 remov\$4) same (UV ultra adj violet ultraviolet wavelengh near3 (nm nanometer nmeter angstrom ".angstrom." excimer))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/12/19 11:00
2	L2	1243	(terpinene limonene terpene cyclohexane trimethylcyclohexane cyclooctadiene dimethylcyclooctadiene camphene adamantane tricyclodecane butadiene decahydronaphthelene dendrimers hyper adj branch\$3) same (dry drying dried evaporat\$4 vaporiz\$6 remov\$4) same (UV ultra adj violet ultraviolet wavelengh near3 (nm nanometer nmeter angstrom ".angstrom." excimer))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/12/19 10:57
3	L3	2	(Norbornadiene) same (dry drying dried evaporat\$4 vaporiz\$6 remov\$4) same (UV ultra adj violet ultraviolet wavelengh near3 (nm nanometer nmeter angstrom ".angstrom." excimer))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/12/19 10:40
4	L4	25213	(427/508-522, 541-542, 552-559, 561-563, 569-579, 249.1-255.395, 430.1).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	2006/12/19 10:41

10/624,356

update + new terms/associations
+ interference search

	L #	Hits	Search Text	DBs	Time Stamp
5	L5	172029	(porous pore porosity porogen micropor\$6 nanopor\$6 void foam) same (silicon structure adj form\$4 oxide dioxide siloxane silane organosiloxane organosilane HMDS OMCTS TMDS OMTS TMS \$methyilsilane \$methyilsiloxane \$phenylsilane \$phenylsiloxane tetraethoxysilane TEOS triethoxysilane \$phenoxysilane \$methoxysilanes \$ethoxysilanes \$Ethylsilane \$butylsilane \$cyclotetrasiloxane \$cyclotrisiloxane \$methyldisiloxane disiloxane trisiloxane \$methyltrisiloxane)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/12/19 10:55
6	L6	53211	(terpinene limonene terpene cyclohexane trimethylcyclohexane cyclooctadiene dimethylcyclooctadiene camphene adamantane tricyclodecane butadiene decahydronaphthelene dendrimers hyper adj branch\$3 norbornadiene) same (silicon structure adj form\$4 oxide dioxide siloxane silane organosiloxane organosilane HMDS OMCTS TMDS OMTS TMS \$methyilsilane \$methyilsiloxane \$phenylsilane \$phenylsiloxane tetraethoxysilane TEOS triethoxysilane \$phenoxysilane \$methoxysilanes \$ethoxysilanes \$Ethylsilane \$butylsilane \$cyclotetrasiloxane \$cyclotrisiloxane \$methyldisiloxane disiloxane trisiloxane \$methyltrisiloxane)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/12/19 10:58
7	L7	962	(L1 or L2 or L3) same (L5 or L6)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/12/19 10:59

L11

L13
L16

	L #	Hits	Search Text	DBs	Time Stamp
8	L8	1036	((L1 or L2 or L3) and (L5 or L6)) not L7	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/12/19 10:59
9	L9	820	(porous pore porosity porogen micropor\$6 nanopor\$6 void) and L7	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/12/19 11:00
10	L10	907	(porous pore porosity porogen micropor\$6 nanopor\$6 void) and L8	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/12/19 11:01
11	L11	5598	((Silicon Si) adj (hydroxide OH) SiOH) with (bond link linkage group functionaliz\$5 free undesirable)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/12/19 11:04
12	L12	32	L9 and L11	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/12/19 11:05
13	L13	25	L10 and L11	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/12/19 11:05
14	L14	172	L9 and ("427"/\$.CCLS. or "438"/\$.CCLS.)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/12/19 11:06

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	L #	Hits	Search Text	DBs	Time Stamp
15	L15	203	(L10 and ("427"/\$.CCLS. or "438"/\$.CCLS.)) Not L13	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/12/19 11:07
16	L16	156	L14 not L12	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2006/12/19 11:07